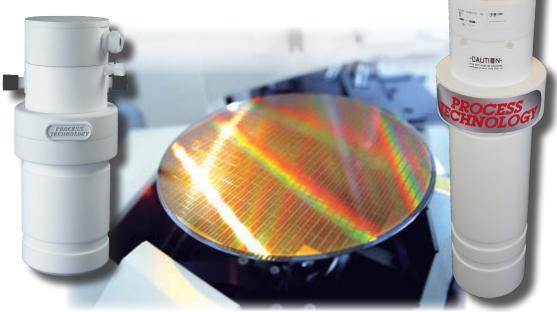
# **TIH** Inline Chemical Heater

Advanced TIH Inline Chemical Heater performs unmatched semiconductor process fluid heating!



### Now heat semiconductor process fluids up to 210°C!

Faster heatup: Single heater chamber sizes up to 18kW.

**Rapid installation:** Customized plumbing connections available to match existing plumbing and case installation.

Long heater life for reduced cost of ownership (COO): Patented heater gas purge system continuously removes any chemical permeation and ensures long element life.

**Long heater life and clean operating:** Patented heater gas purge system continuously removes chemical permeation and ensures exceptionally long element life. This system also protects against any potential ionic contamination of the chemistry.

**Rugged construction:** Thick walled chamber provides long service life in the harshest high temperature applications.

**Exceptionally clean performance:** Thick fluoropolymer sheath minimizes permeation. Element purge monitoring minimizes ionic contamination potential. Cleanroom assembly and testing ensures the highest manufacturing standards.

**Outstanding chemical compatibility:** All fluoropolymer wetted parts compatible with virtually any chemistry.

**Excellent temperature stability:** Low watt density design enables accurate control of process temperature.

#### **TIH Series Applications Include:**

- SC1: ammonium hydroxide (NH₄OH), and hydrogen peroxide (H₂O₂)
- SC2: hydrochlorice acid (HCI) and hydrogen peroxide
- Buffered oxide etch (BOE) process: hydrofluoric acid (HF) and ammonim fluoride (NH₄F)
- Nitride etch/strip: phosphoric acid (H<sub>3</sub>PO<sub>4</sub>)
- Various acids such as:
- Hydrochloric (HCl)
- Hydrofluoric (HF)
- Acetic (C<sub>2</sub>H<sub>4</sub>O<sub>2</sub>)
- Nitric (HNO<sub>3</sub>)
- Sulfuric (H<sub>2</sub>SO<sub>4</sub>)
- Sulfuric acid and hydrogen peroxide
- Sulfuric acid and ozone (O<sub>3</sub>)
- Hydrofluoric acid and glycol (C2H6O2)
- Potassium hydroxide (KOH)
- Sodium hydroxide (NaOH)
- Electroless nickel
- Electroless copper
- Electroless gold
- Deionized water
- Some solvents (consult factory)



# **TIH Benefits and Specifications**

- Unmatched heating of semiconductor process fluids up to 210°C.
- Patented heater gas purge system ensures long element life and reduced cost of ownership.
- Thick walled chamber provides long service life in the harshest high temperature applications.
- Element purge monitoring minimizes ionic contamination potential. Cleanroom assembly and testing ensures the highest manufacturing standards.
- All fluoropolymer wetted parts provide outstanding compatibility with virtually any chemistry.
- Low watt density design enables precise and stable control of process temperature.
- PVDF high temperature mounting brackets (High temperature model)

#### **Options:**

- Horizontally mounted configuration
- Integral cooling coils
- 100 ohm RTDs or "J", "K", or "E" type process and element thermocouples
- · Lower watt density heaters for special applications

#### Specifications:

Service:

• Inline chemical heater with all fluoropolymer wetted surfaces for virtually any wet chemistry application.

Temperature Range: Up to 210°C.

#### Maximum Working Pressure:

- 100 PSIG (7 Bar) at 25°C
- 43 PSIG (. Bar) at 180°C

Heater Sizes: 1,000 watts up to 18,000 watts

Heater Voltages Available:

• 200 to 600 volts, single or three phase (12kW and larger requires three phase).

Watt Density: 10 watts per square inch (1.5w/cm<sup>2</sup>)

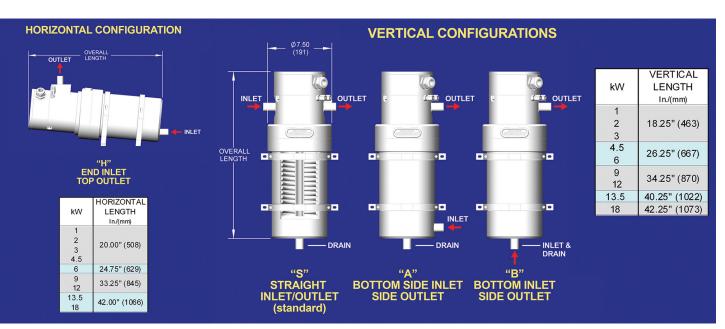
#### Fluid Connections Available:

- <sup>1</sup>/<sub>4</sub>" (6mm) to 1" (25mm) flared
- 1/2" (12mm) to 1" (25mm) Super 300 Type Pillar®
- · Other connections available, consult factory

Third Party Certificatons: CE, UL, Semi S2 and S3

#### Element Purge:

 Small amount of clean dry air (CDA) or N<sub>2</sub> gas flows between the metal grounded element and the PTFE sheath



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## Dimensions